

Notice of References Cited

 Application/Control No.
 09/606,040

 Applicant(s)/Patent Under
 Reexamination
 SIGRIST ET AL.

 Examiner
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 Art Unit
 1656

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*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification	
	A	US-5,563,056	10-1996	Swan et al.	435	180
	B	US-5,154,808	10-1992	Miyasaka et al.	204	157.15
*	C	US-5,858,802	01-1999	Chai-Gao et al.	436	524
	D	US-				
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	K	US-				
	L	US-				
	M	US-				

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*	N	WO 96/31557	10-1996	WO	Jacobsen et al.	C08J	7/18
*	O	WO 91/16425	10-1991	WO	Sigrist et al.	C12N	11/06
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NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	Leonard et al. ("ToF-SIMS and XPS Study of Photoactivatable Reagents Designed for Surface Glycoengineering", Surface and Interface Analysis, 26, pp. 793-799, 1998).
	V	Chevrolot et al. ("Synthesis and Characterization of a Photoactivatable Glycoaryldiazirine for Surface Glycoengineering", Bioconjugate Chem. 10, pp. 169-175, 1998).
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*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
 Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.